



Biggest Opportunities and Challenges of our Lifetimes

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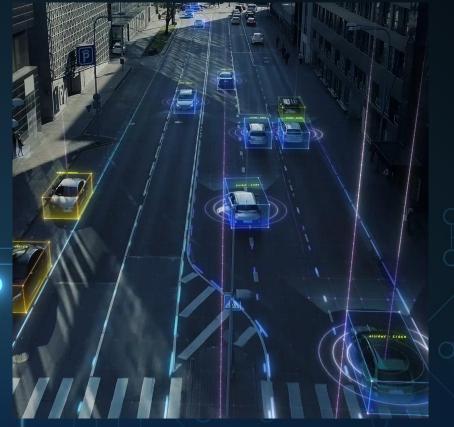
Forward-Looking Statements

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AGRICULTURE EDUCATION HEALTHCARE TRANSPORTATION



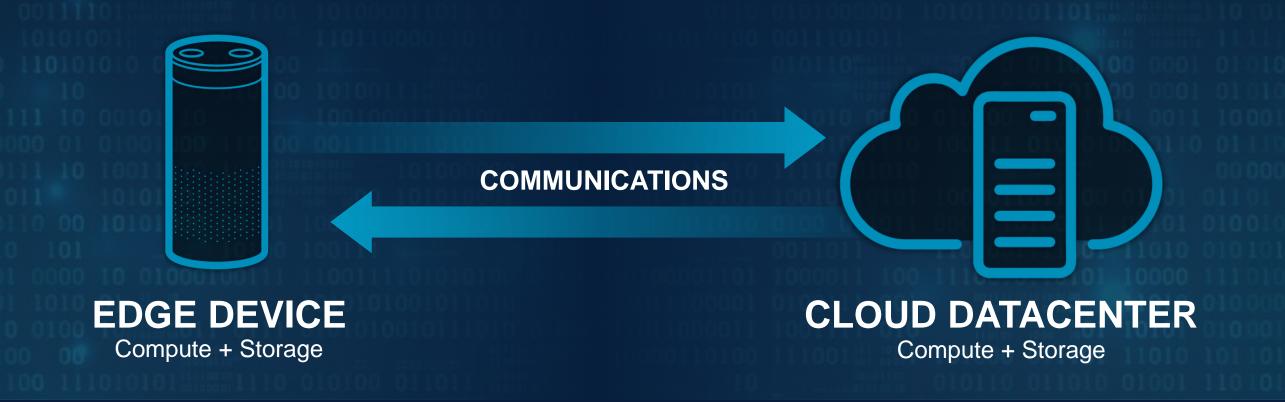




"In the future, every business will be in the technology business"







Compute and store at EDGE vs. CLOUD determined by 3 "laws"

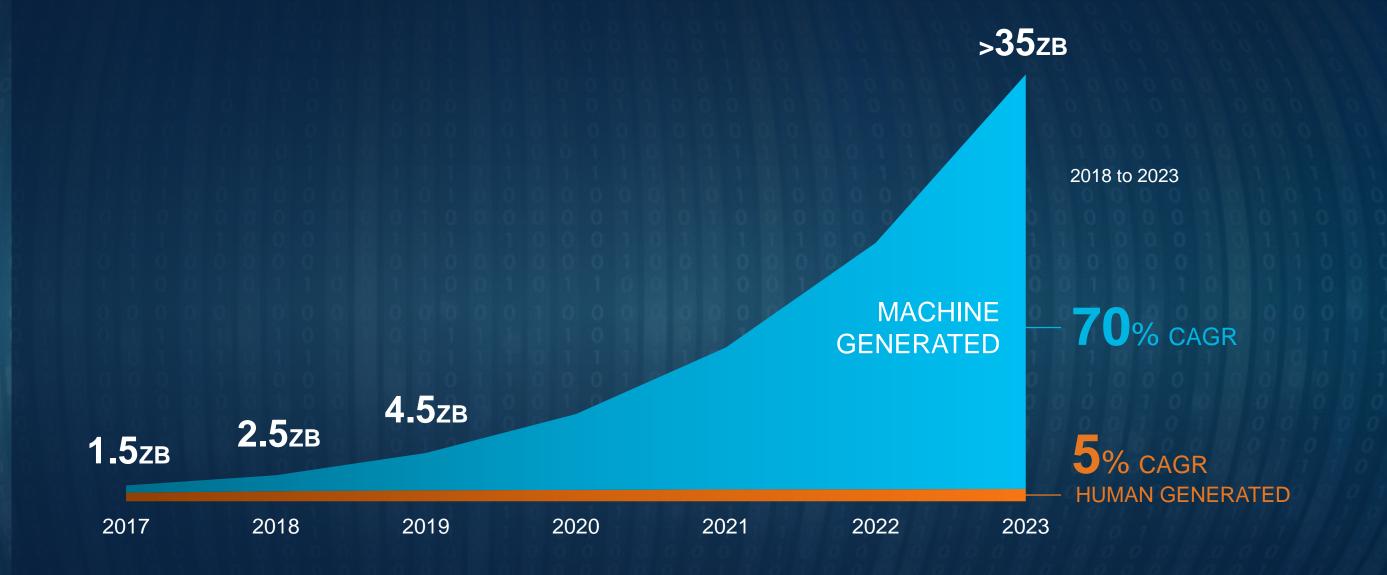
- 1. Law of the land
- 2. Law of physics
- 3. Law of economics







EXPLOSION OF DATA GENERATION







GENERAL PURPOSE COMPUTING

(GOOD AT MANY THINGS)

A.I. COMPUTING

(CUSTOMIZED FOR SPECIALIZED TASKS)

Multi-level on-die cache architecture

High Speed Memories

To improve memory latency and memory to logic bandwidth

Deep instruction pipeline, out-of-order execution, branch prediction, pre-fetching, ...

Extreme Parallelism

Simple operations on multiple chunks of data in parallel

64 bit or higher precision data paths

Lower Precision

Training and inference at lower floating point (16 bit) and integer (8 bit) precision

New Computing Approaches Needed to Unlock Value of Data Explosion



FASTEST GROWING A.I. WORKLOADS ARE VISUAL

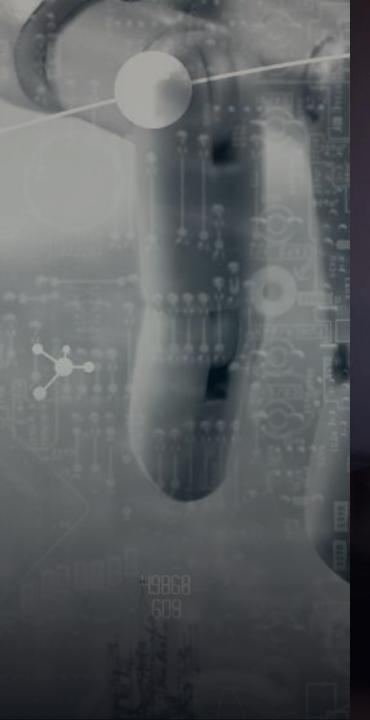






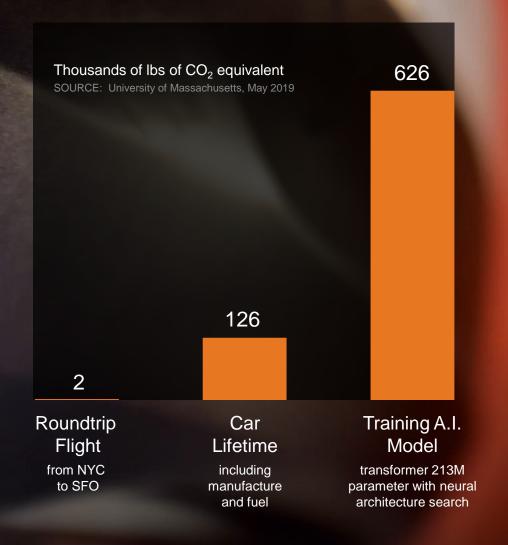
	VISUAL	AUDIO	TEXT / NUMERIC
Examples	IP / Security cameras Autonomous vehicles Robotics	Voice assistants Wearables Call Centers	Search optimization Advertising Business intelligence
Neural Network (NN) Type	Convolutional NN (CNN)	Recurrent NN (RNN) or CNN	Multilayer Perceptron (MLP)
% of total NN use today	10%	25%	65%
% of total NN use 2025	45%	15%	40%





"Training a single A.I. model can emit as much carbon as five cars in their lifetimes"

MIT TECHNOLOGY REVIEW, JUNE 2019

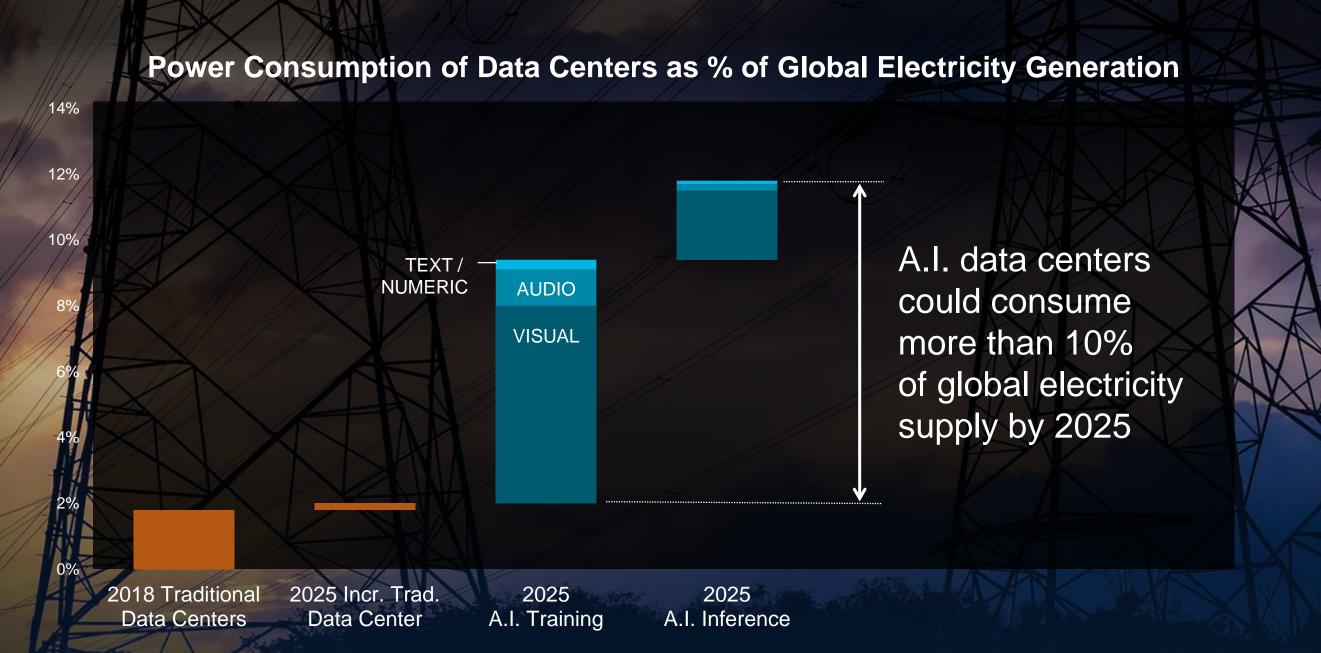


Energy Consumption Could Become a Key Constraint to Growth of A.I.

SHEER NUMBER
OF EDGE DEVICES
CAN CHANGE
WORLD'S ENERGY
EQUATION



IMPACT OF SCALING THE CLOUD IS EVEN MORE SIGNIFICANT



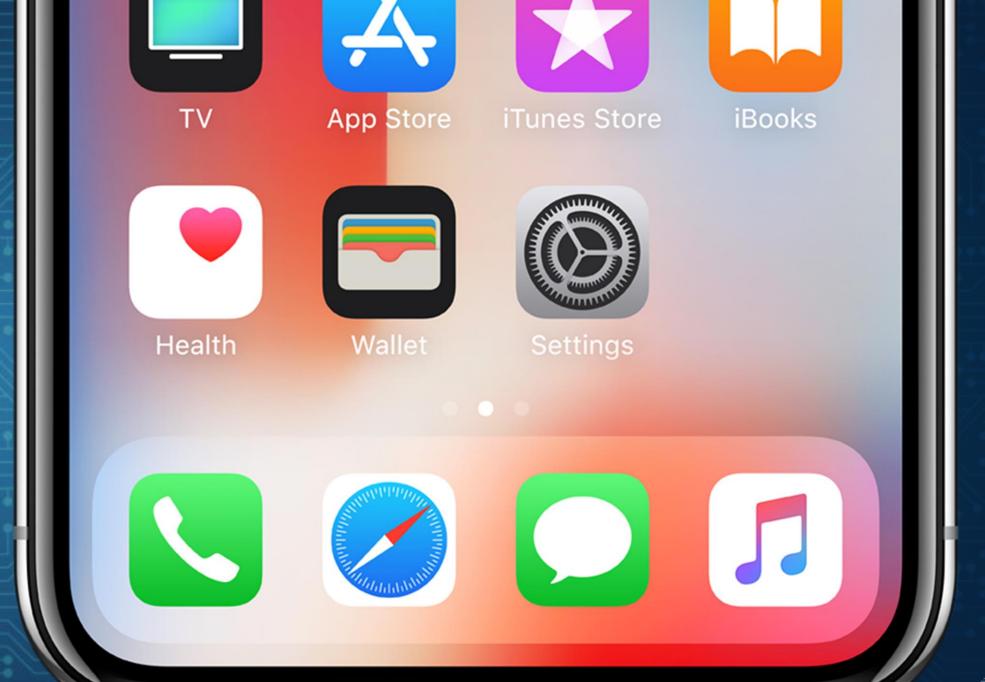


from 1980s...

14 Meters

600kW

\$100M

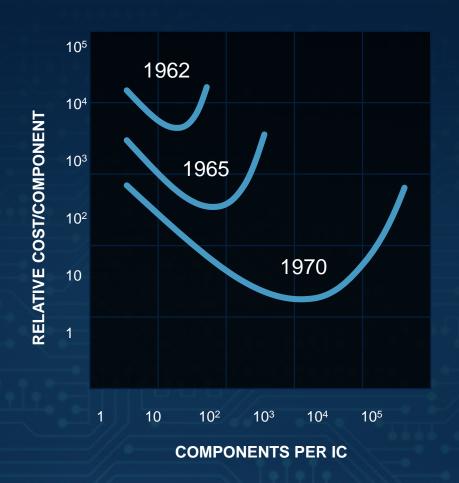


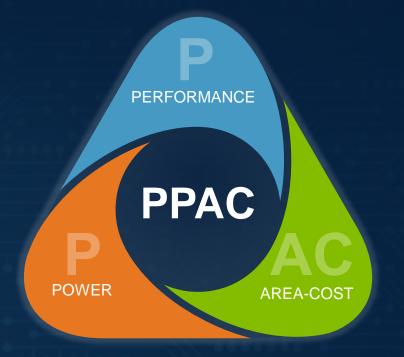


FOR YEARS

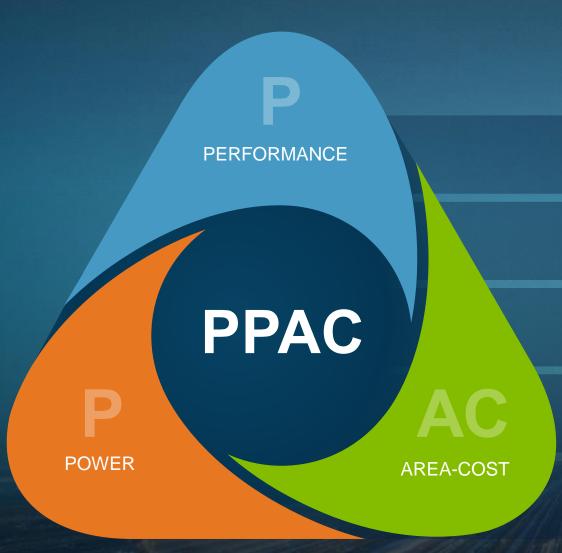
MOORE'S LAW

IMPROVEMENTS IN...









ENABLED BY

New architectures

New structures / 3D

New materials

New ways to **shrink**

Advanced packaging

A New Playbook for Semiconductor Design and Manufacturing is Needed



Major advances at edge and in cloud needed to realize potential of A.I. without impacting world's energy equation

CLOUD

NEEDED VS. CURRENT SOLUTION (GPU)

75x throughput and

1,000x

performance per watt

Limited impact on roadmap

EDGE

NEEDED VS. CURRENT SOLUTION (CPU)

50x

better latency and

NFERENCE

500x

throughput

NEEDED VS. CURRENT SOLUTION (CPU)

50x

better latency and

75x

throughput

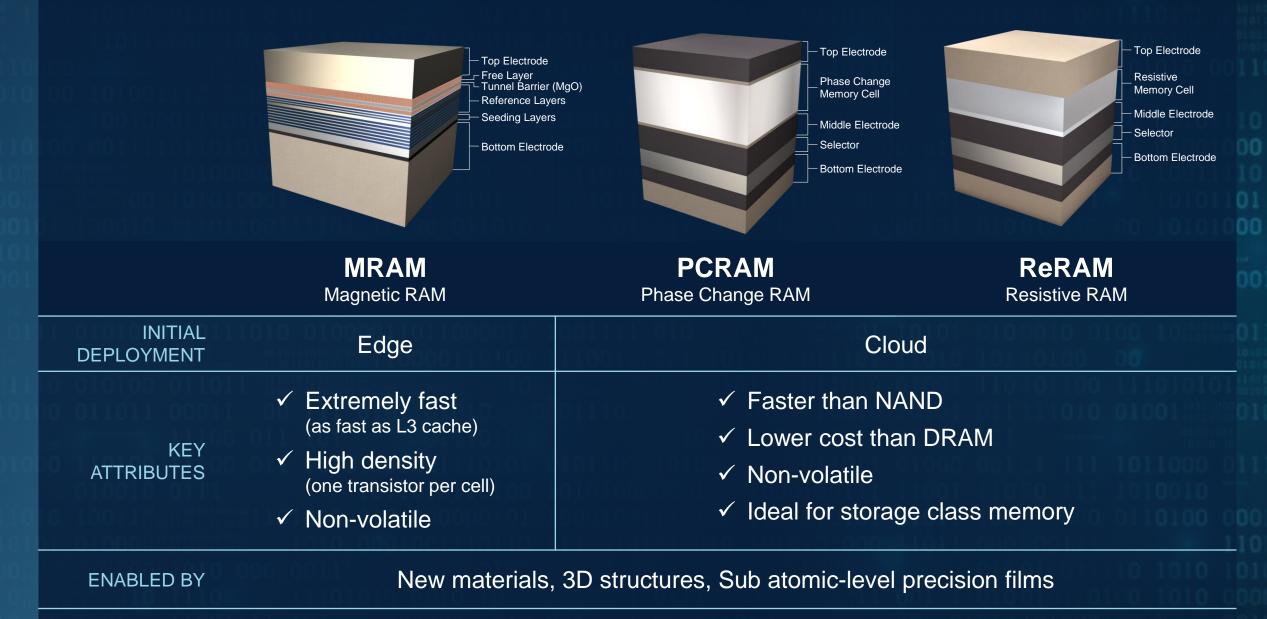




Promising Pipeline of New Hardware Innovations



ENABLING ROADMAP REQUIRES NEW APPROACHES TO MANUFACTURING





Endura[®] Clover[™] MRAM PVD platform

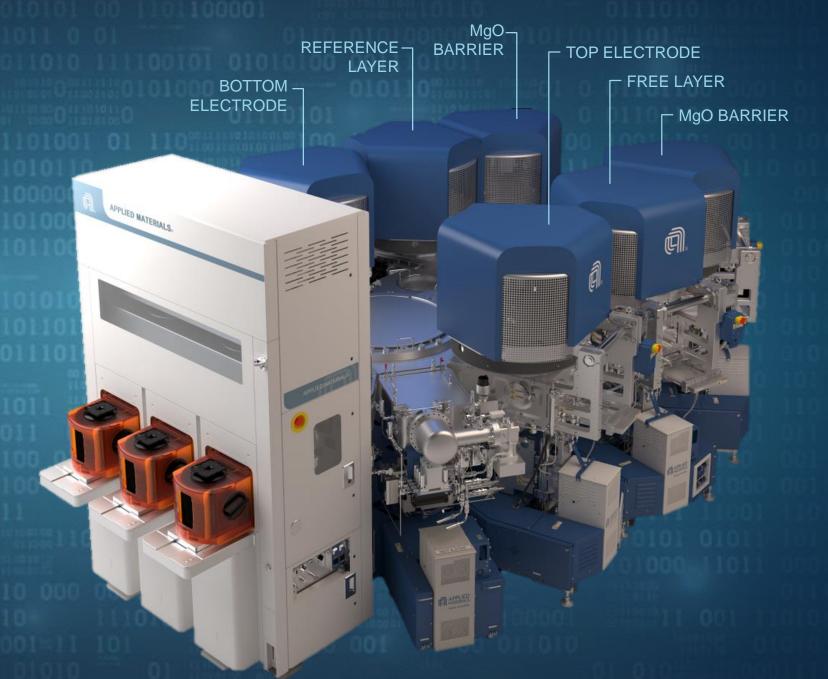
Integrated Materials Solution

9 chambers

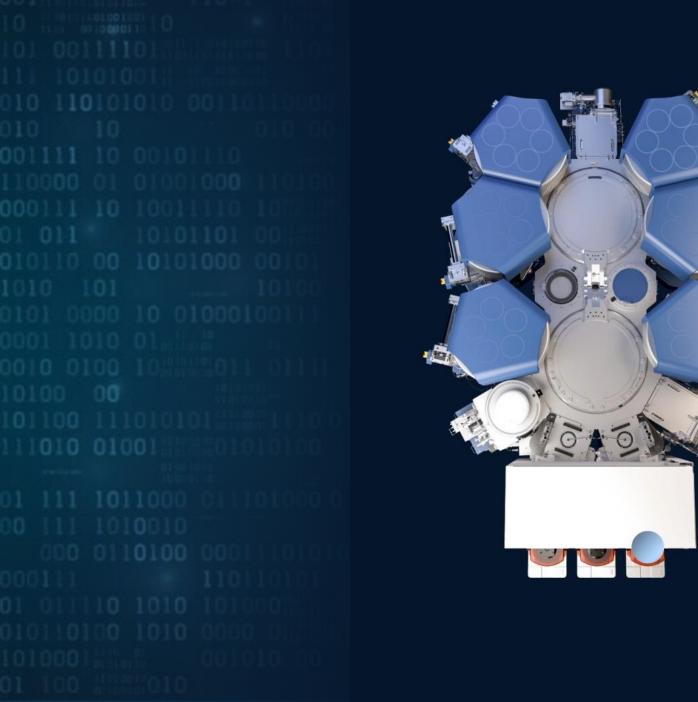
Up to 5 materials per chamber

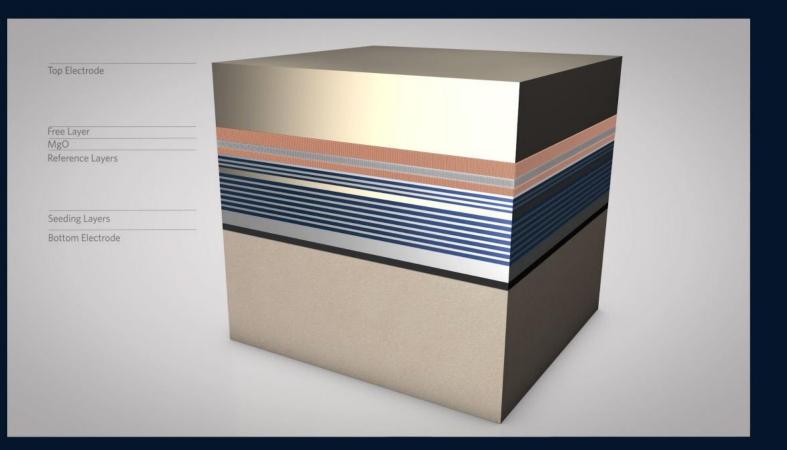
On-board metrology

"Fab inside a fab"









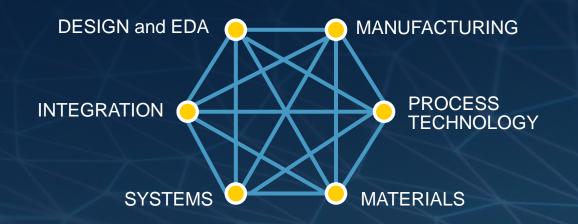


APPLIED MATERIALS.

"Von Neumann" mindset vs. "Neuromorphic" mindset



TODAY: Serial / compartmentalized interaction between key parts of ecosystem



OPPORTUNITY: Parallel development to get powerful tools to designers faster

Ecosystem Collaboration is Key to Accelerating A.I. Adoption

























MAYDAN TECHNOLOGY CENTER

PROCESS

TECHNOLOGY

State of the art 300mm process technology lab

META CENTER

opening fall 2019

'Lab to fab' accelerator

ADVANCED PACKAGING LAB

Fully integrated 300mm advanced wafer level packaging lab

ADVANCED MATERIALS LAB

Foundational materials engineering R&D

Applied's Collaborative R&D Platform to Accelerate Materials to Systems 10x



A.I. GRAND CHALLENGES

IMPROVE COMPUTE PERFORMANCE / WATT

ACCELERATE
MATERIALS TO SYSTEMS

1,000x

10X